

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Confirmation No. 3771

Yoichiro NUMASAWA et al.

Docket No. 2003_1106A

Serial No. 10/642,619

Group Art Unit 1754

Filed August 19, 2003

Examiner Ngoc Yen M. Nguyen

APPARATUS AND METHOD FOR MANUFACTURING HALOGEN GAS AND HALOGEN GAS RECOVERY AND CIRCULATORY SYSTEM

THE COMMISSIONER IS AUTHORIZED TO CHARGE ANY DEFICIENCY IN THE FEES FOR THIS PAPER TO DEPOSIT

ACCOUNT NO. 23-0975

PATENT OFFICE FEE TRANSMITTAL FORM

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached hereto is a check in the amount of \$450.00 to cover Patent Office fees relating to filing the following attached papers:

Petition for Extension of Time \$450.00

A duplicate copy of this paper is being submitted for use in the Accounting Division, Office of Finance.

The Commissioner is authorized to charge any deficiency or to credit any overpayment associated with this communication to Deposit Account No. 23-0975, with the EXCEPTION of deficiencies in fees for multiple dependent claims in new applications.

Respectfully submitted,

Yoichiro NUMASAWA et al.

David M. Ovedovitz Registration No. 45,336

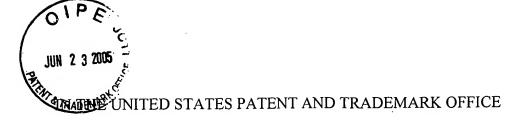
for

Jeffrey R. Filipek

Registration No. 41,471 Attorney for Applicants

DMO/JRF/fs WENDEROTH, LIND & PONACK, L.L.P. 2033 K St., N.W., Suite 800 Washington, D.C. 20006-1021 Telephone (202) 721-8200 June 23, 2005

[Check No. 6897]



In re application of

Confirmation No. 3771

Yoichiro NUMASAWA et al.

Docket No. 2003_1106A

Serial No. 10/642,619

Group Art Unit 1754

Filed August 19, 2003

Examiner Ngoc Yen M. Nguyen

APPARATUS AND METHOD FOR MANUFACTURING HALOGEN GAS AND HALOGEN GAS RECOVERY AND

CIRCULATORY SYSTEM

RESPONSE

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 THE COMMISSIONER IS AUTHORIZED TO CHARGE ANY DEFICIENCY IN THE FEES FOR THIS PAPER TO DEPOSIT ACCOUNT NO. 23-0975

Sir:

Pursuant to the requirement contained in the Office Action mailed March 24, 2005, the period for response to which having been extended by two months to June 24, 2005, Applicants hereby elect invention I, claims 1-7, drawn to a process for manufacturing halogen gas.

In view of this election, a full examination on the merits of the present application is respectfully requested.

Respectfully submitted,

Yoichiro NUMASAWA et al.

Rv

David M. Ovedovitz

Registration No. 45,336

for

Jeffrey R. Filipek

Registration No. 41,471

Attorney for Applicants

DMO/JRF/fs Washington, D.C. 20006-1021 Telephone (202) 721-8200 Facsimile (202) 721-8250 June 23, 2005